

Test & Reliability

Rijuta Bagchi



ICSCRM 2025

14-19 September 2025

BEXCO, Busan, Korea



Fraunhofer Institute for Integrated
Systems and Device Technology IISB

soitec

cea

leti

Impact of current density, accumulated injected charge and temperature on bipolar degradation in 4H-SiC PiN diodes

Authors: R. Bagchi¹⁾, J. Leib¹⁾, F. Allibert²⁾, F. Dresel¹⁾, E. Guiot²⁾, J. Biscarrat³⁾, C. Le Royer³⁾ and B. Eckardt¹⁾

¹⁾ Fraunhofer IISB, Erlangen, Germany

²⁾ Soitec, Parc Techno des Fontaines, France

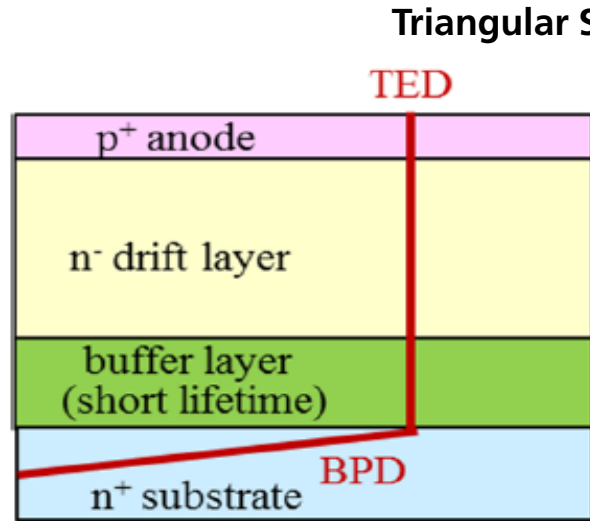
³⁾ Univ. Grenoble Alpes, CEA, Leti, France



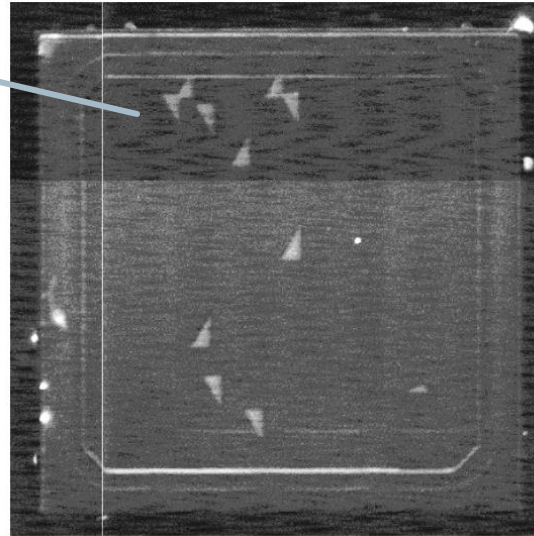
**Download
Presentations**

Introduction

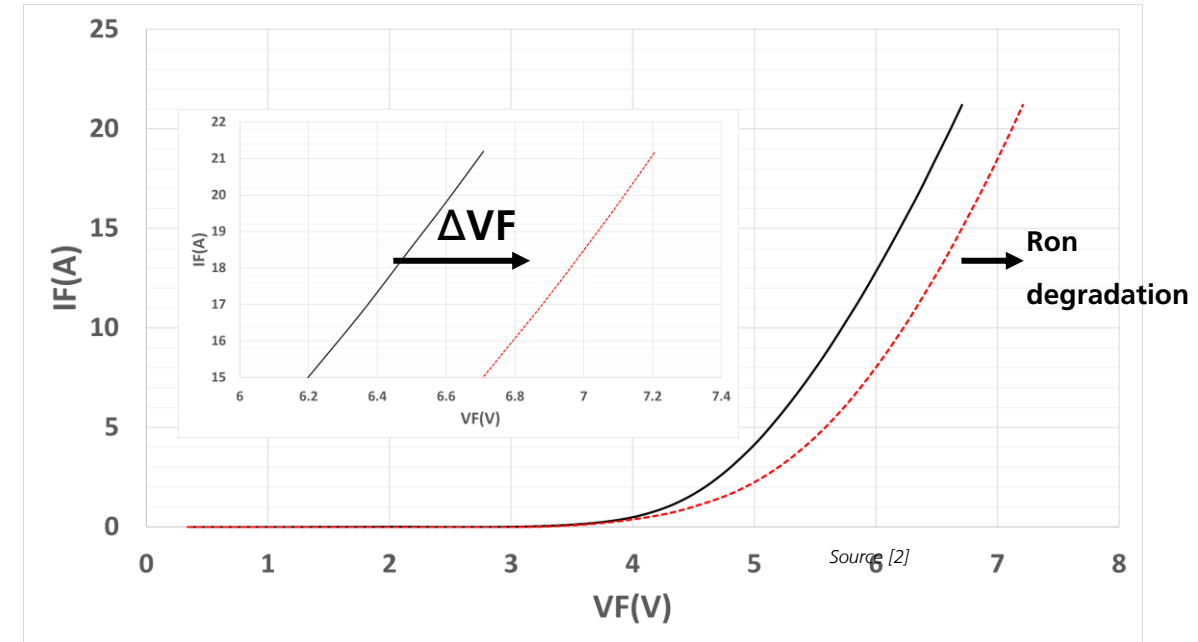
Bipolar Degradation



Source [1]



Source [2]



- **Bipolar Degradation (BD) :**

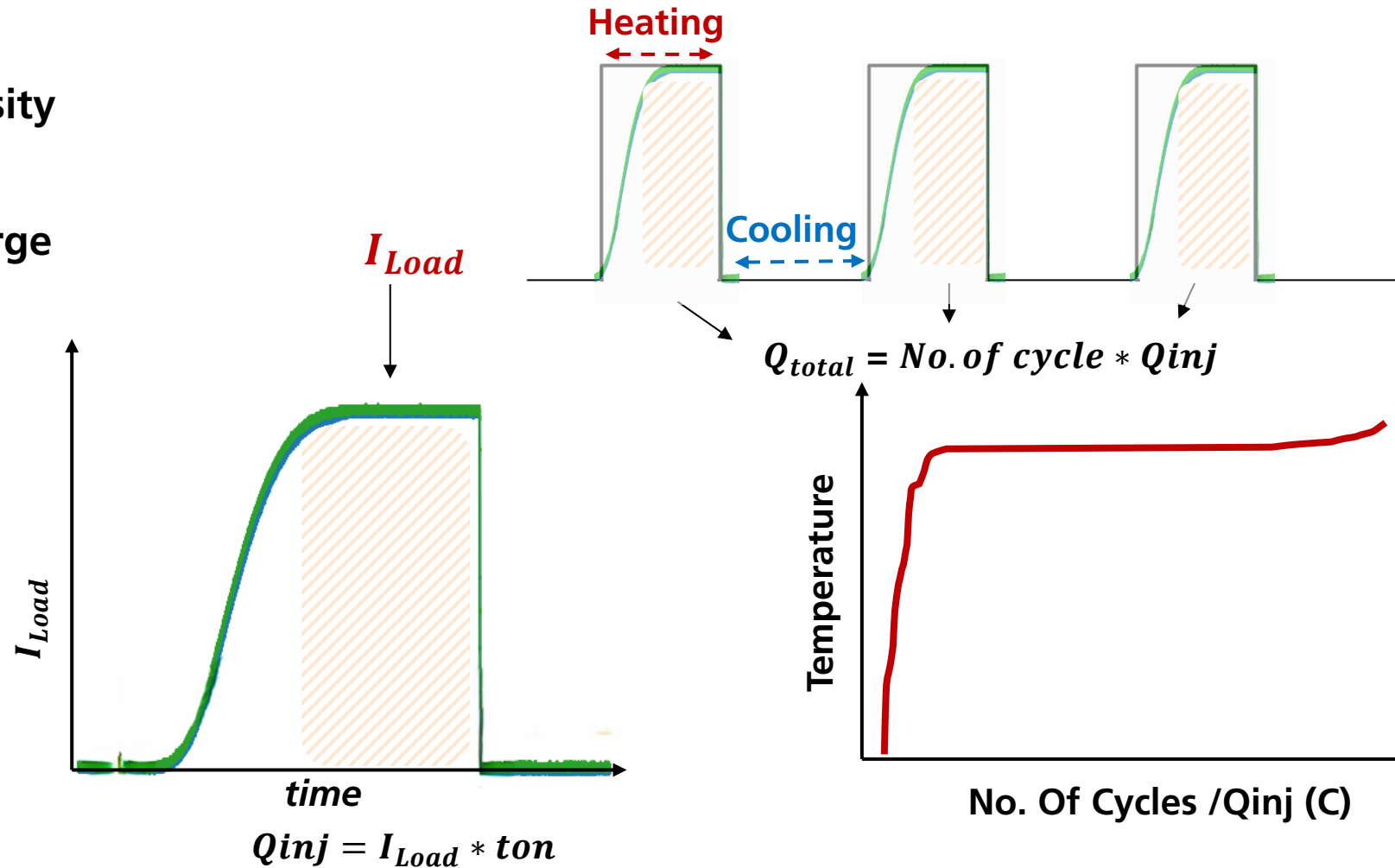
Bipolar currents -> Stacking faults (SSFs) expansion ->

Resistance increase -> Forward Voltage degradation

Targets of this study

Impact of Temperature, Current density and Injected Charge

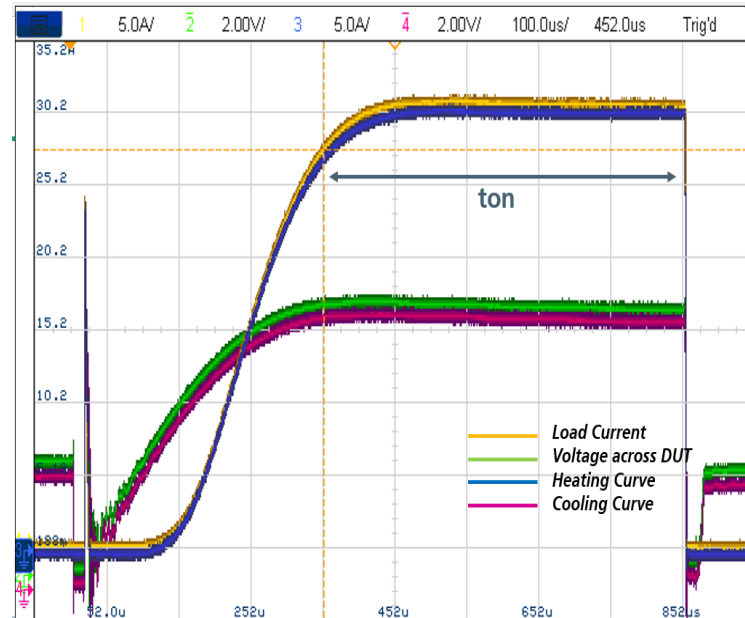
- Current density
- Temperature
- Injected charge



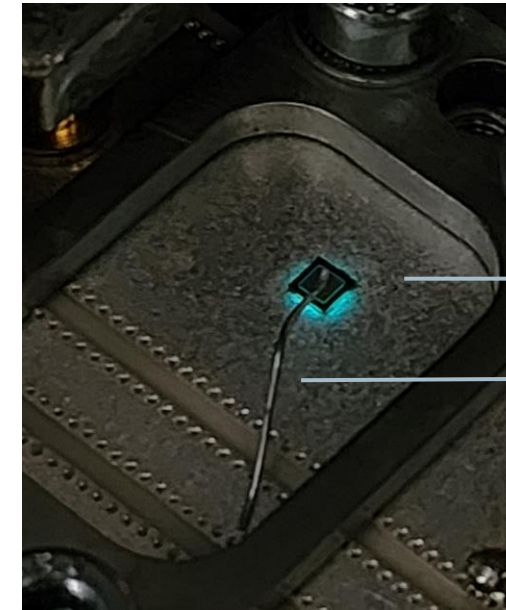
Test Setup

Original Setup

- Two-point measurement
- Bond-Wire (BW) aging
- Significant increase of VF
- Not possible to compare in-situ



Pulse Shape - PCmsec

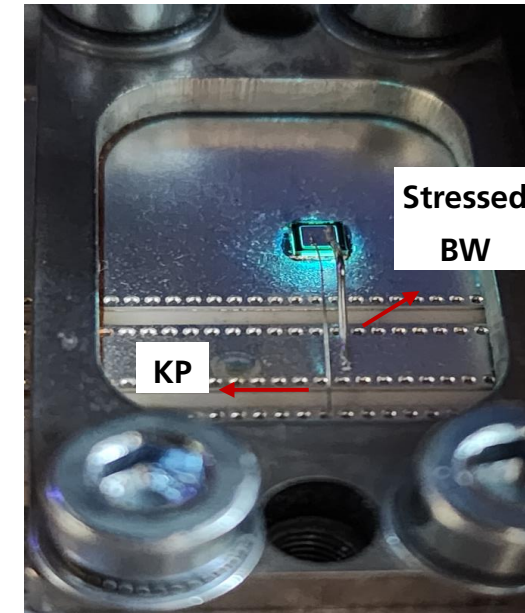
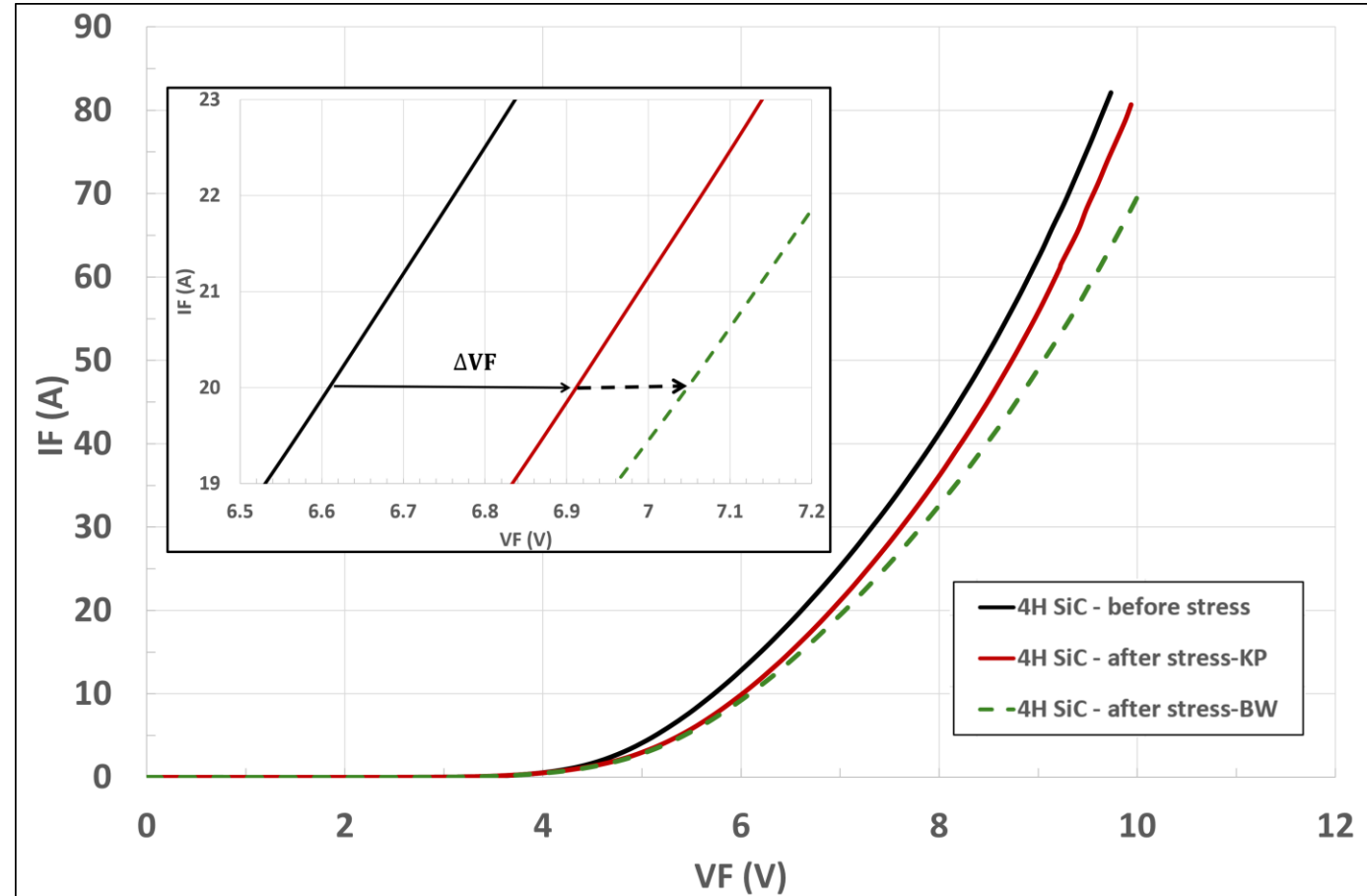


DUT mount with direct cooling

Improved Setup

Kelvin-Probe implementation

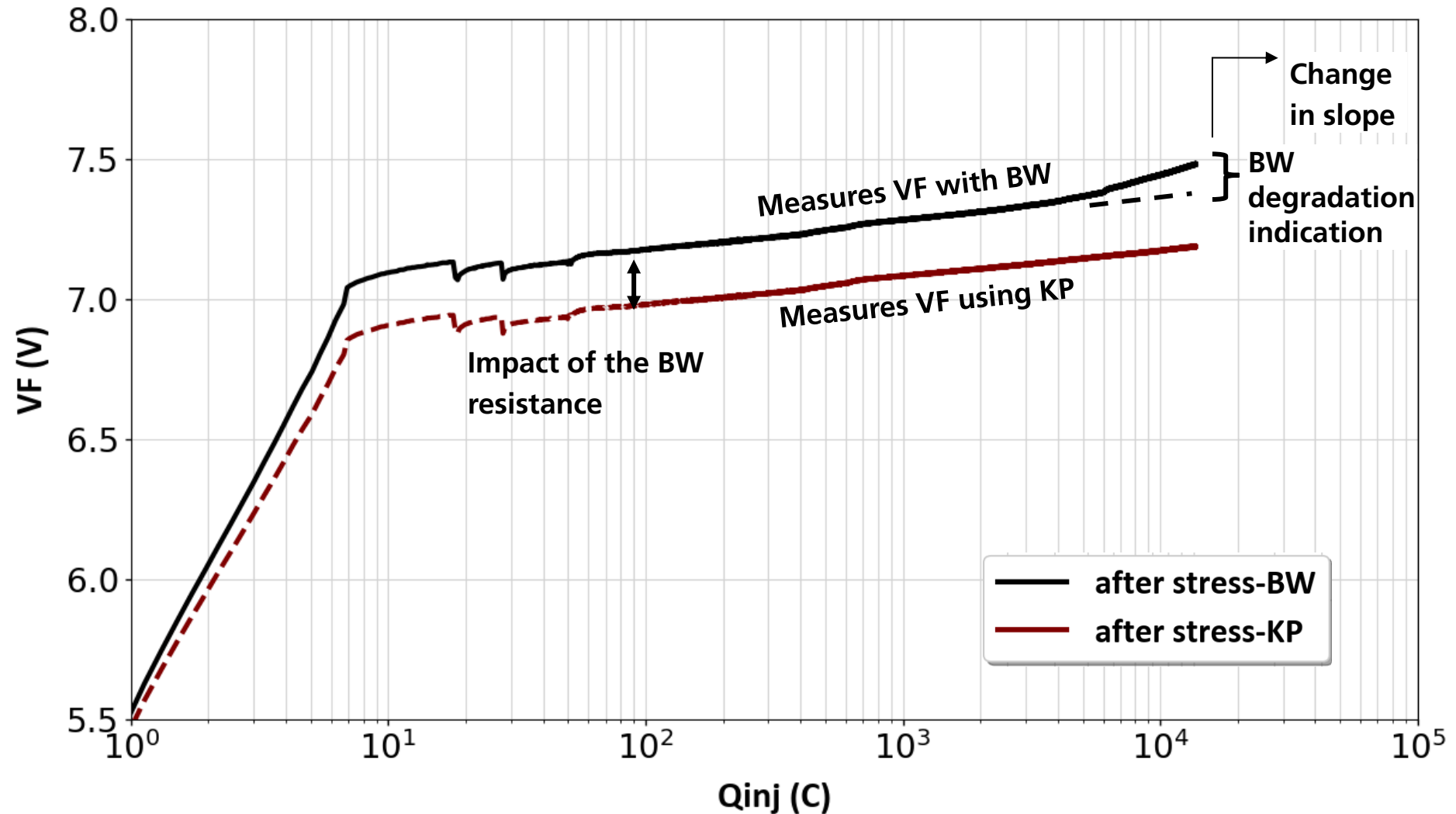
- The measurements including the BW led to a significant error in the forward voltage measurement.
- Solution: Introduced Kelvin-Probe measurement.



Characteristic features of the measurement curves

Impact of Bond-Wire Resistance

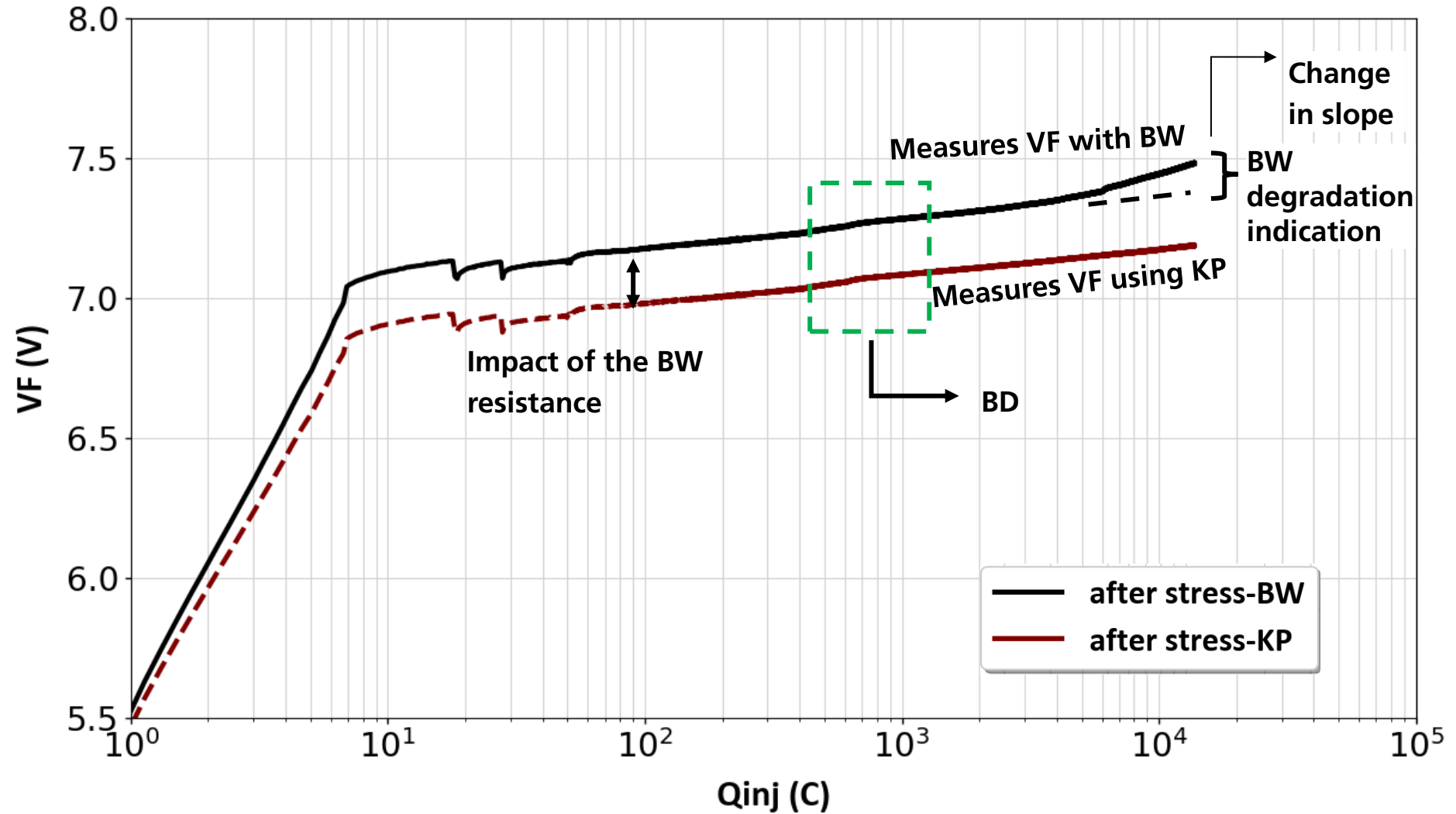
- Accurate VF measurement
- Ability to differentiate BW degradation from BD, **In-Situ**



Characteristic features of the measurement curves

Signature of Bipolar Degradation

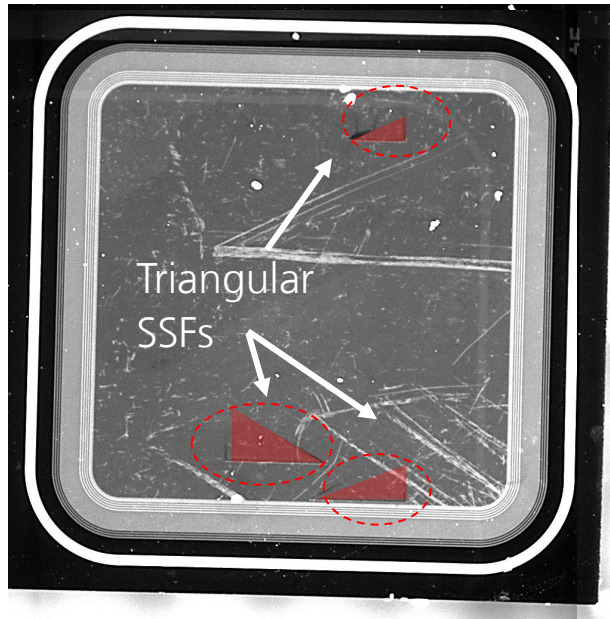
- Skewness observed in curve



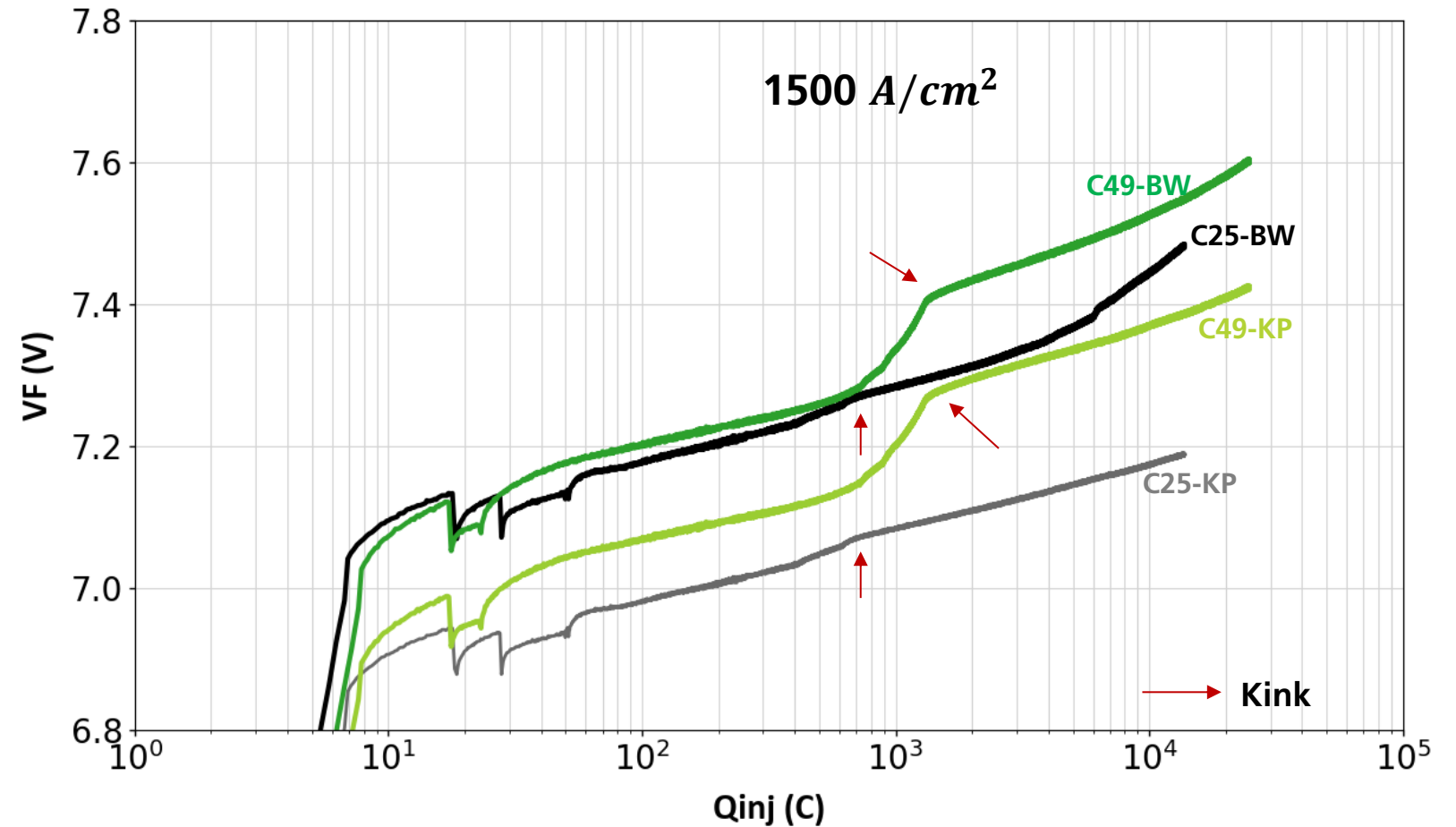
Characteristic features of the measurement curves

Signature of Bipolar Degradation

- Observed kink in the curve, a signature for bipolar degradation.



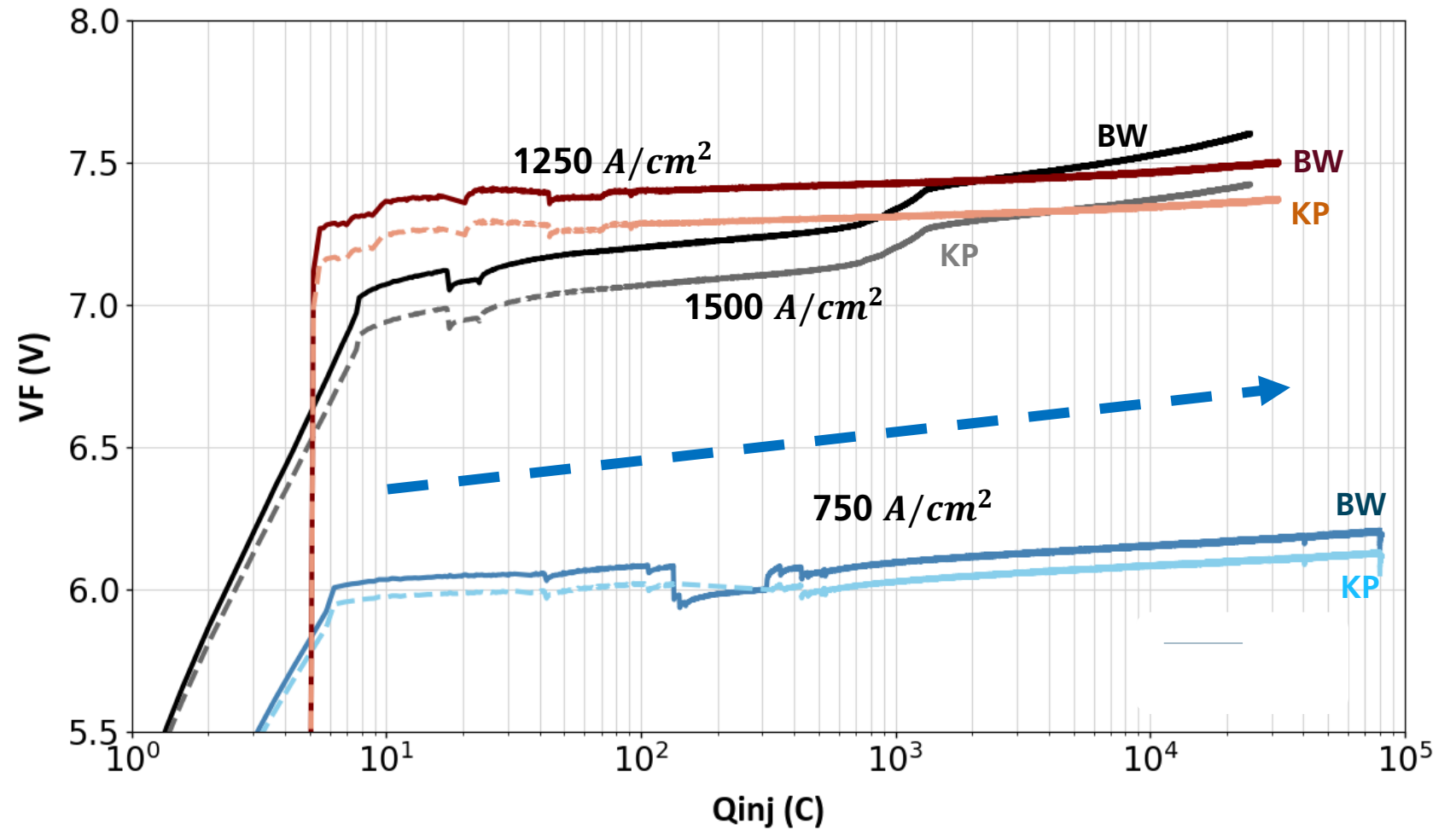
DUT C25 After stress- UV-PL image



Characteristic features of the measurement curves

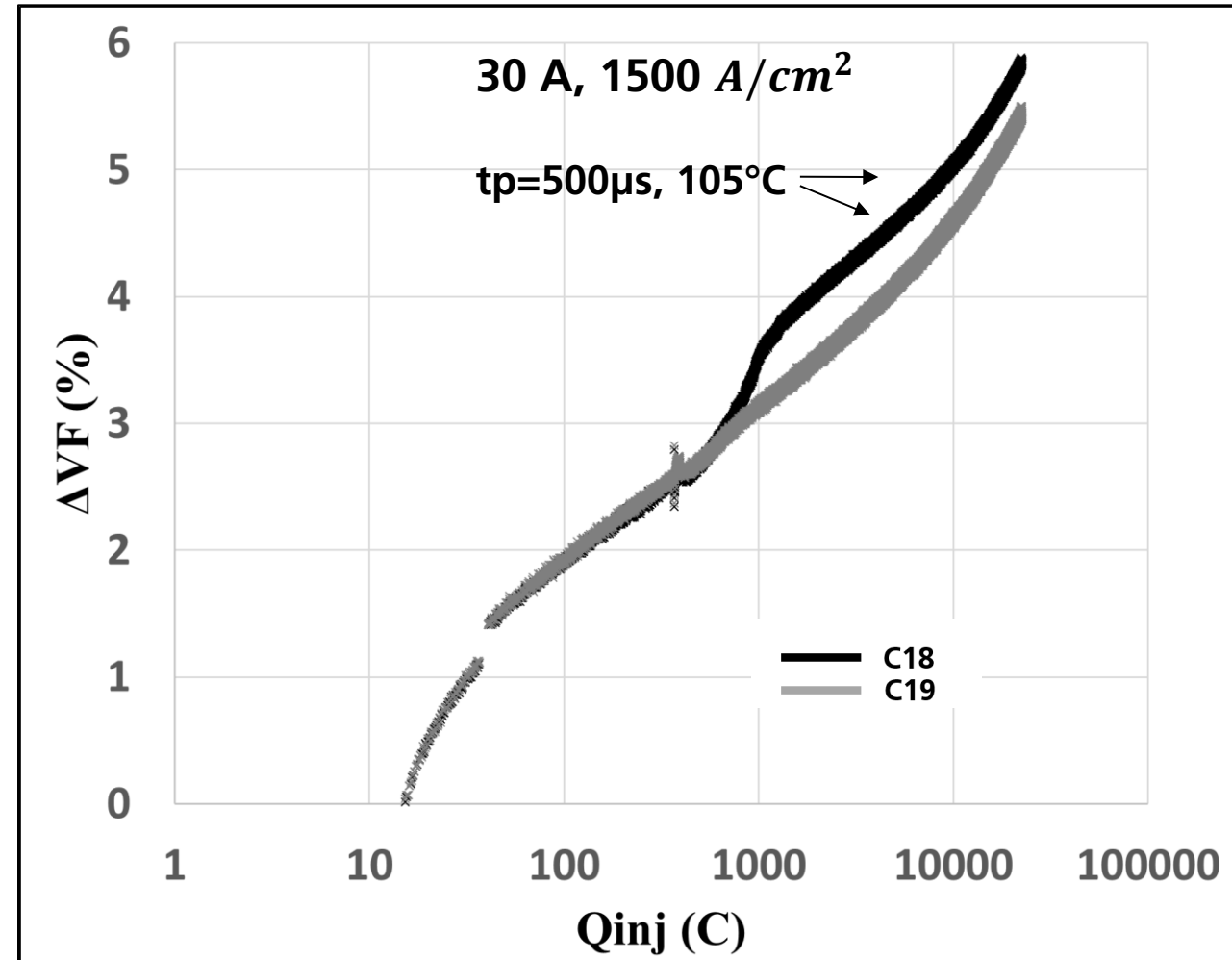
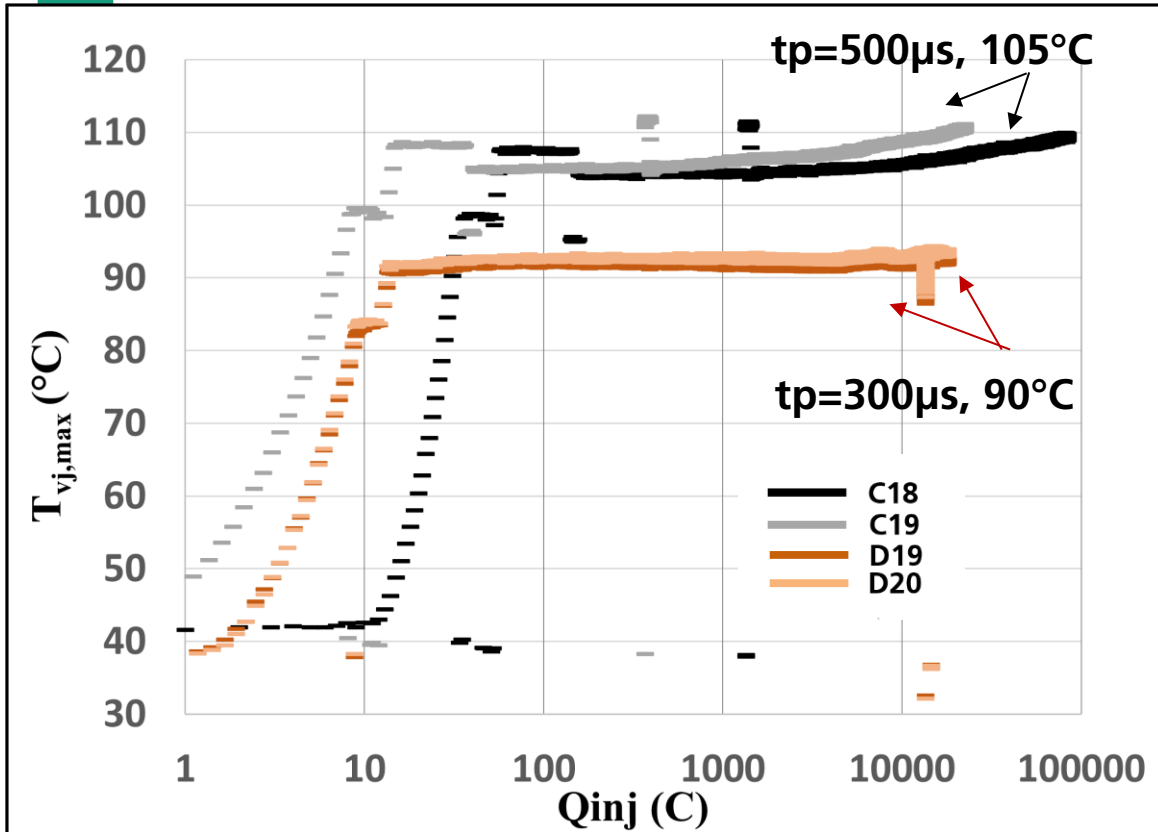
Systematic increase in VF

- Gradual increase in VF
- Present in all stress conditions
 - not Bond Wire degradation
 - not Bipolar Degradation



Impact of Temperature

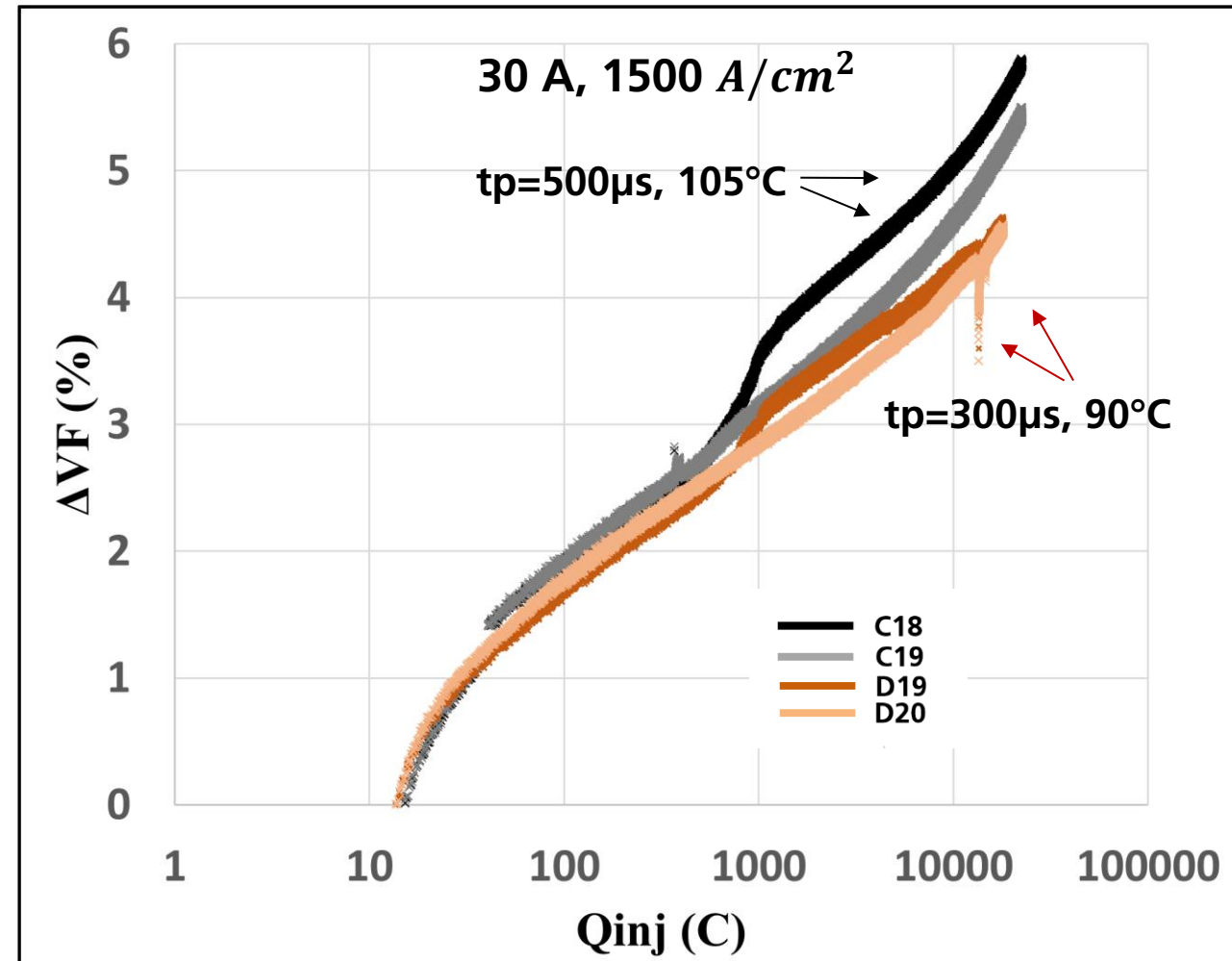
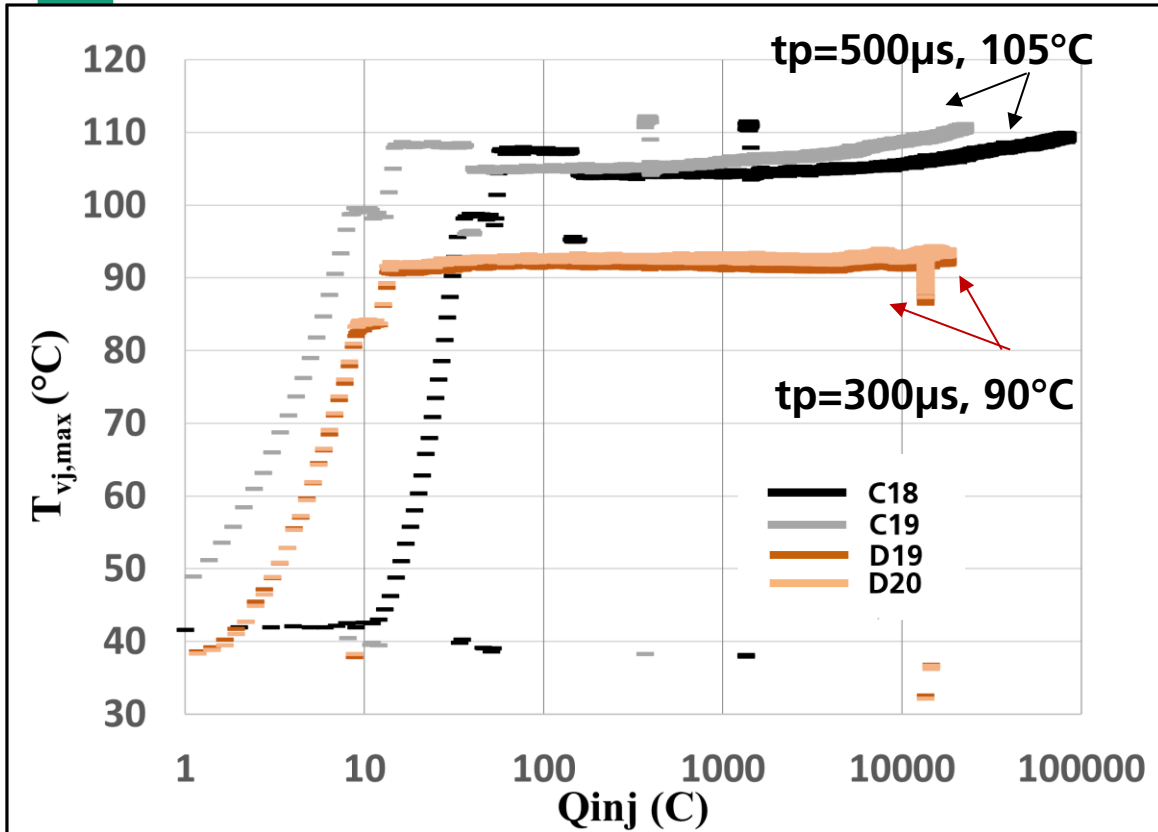
Temperature control by Pulse Width variation



- Change in duration of the load current (I_L) influences the value of $T_{vj,max}$.

Impact of Temperature

Temperature control by Pulse Width variation

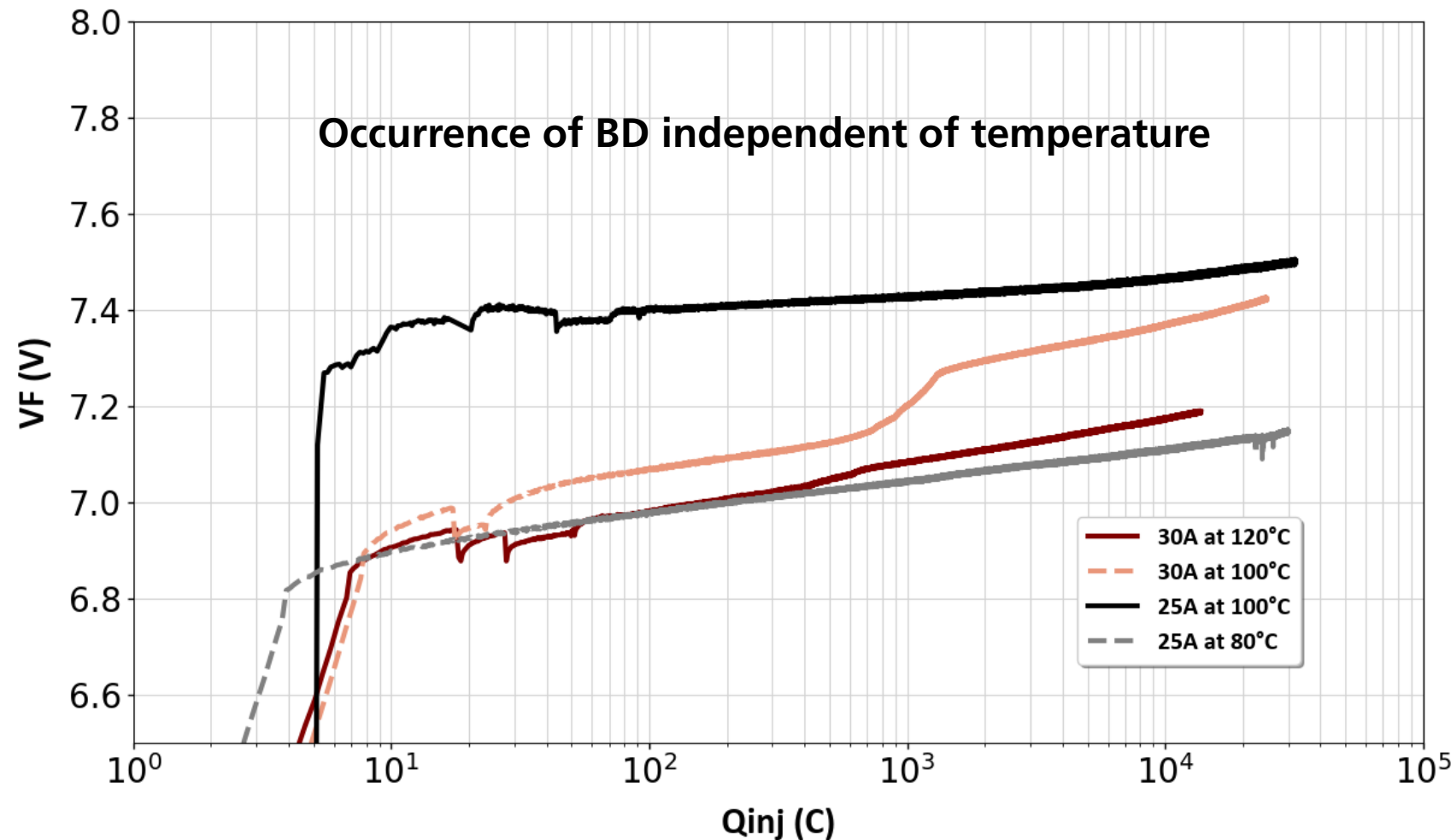


- Temperature doesn't have a first order impact.

Impact of Temperature

Temperature control by chiller

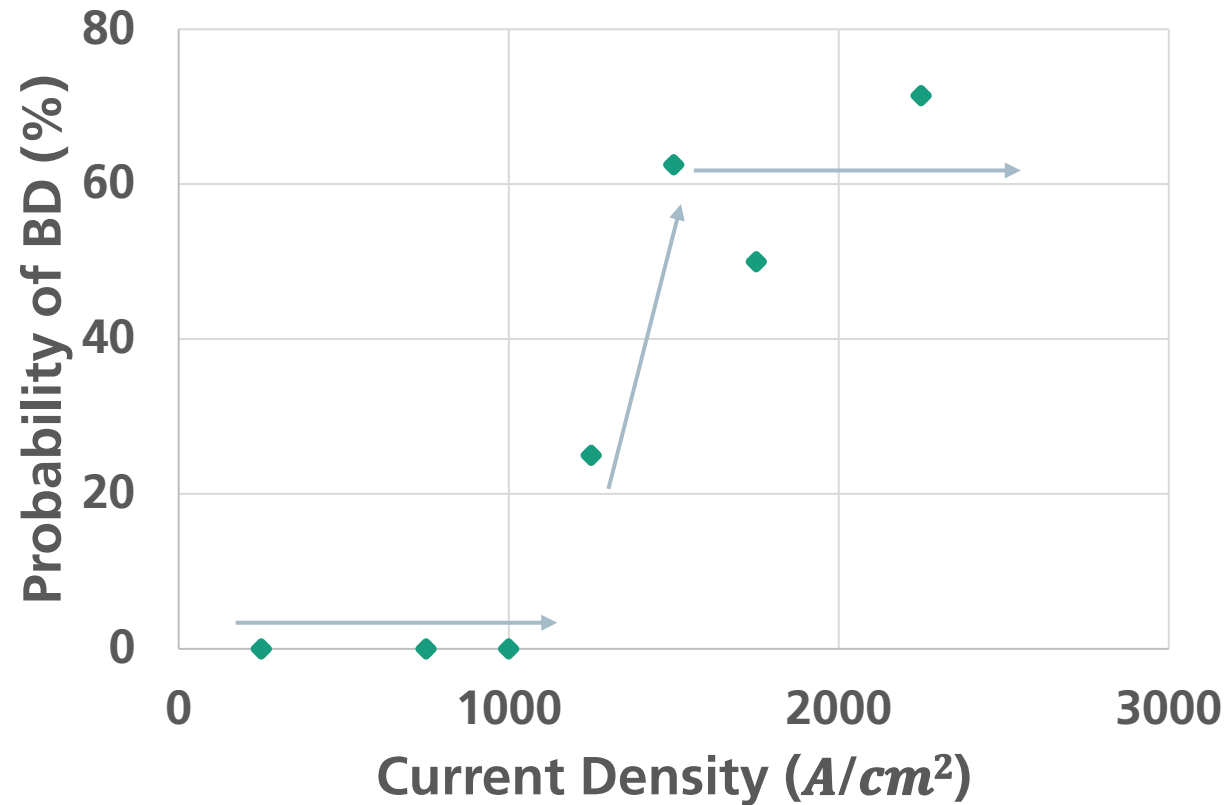
- Removes possible influence of Pulse Width
- Several DUTs -> same Pulse Width but at different $T_{vj,max}$,
- No direct consequence on Bipolar Degradation



- Temperature doesn't have a first order impact.

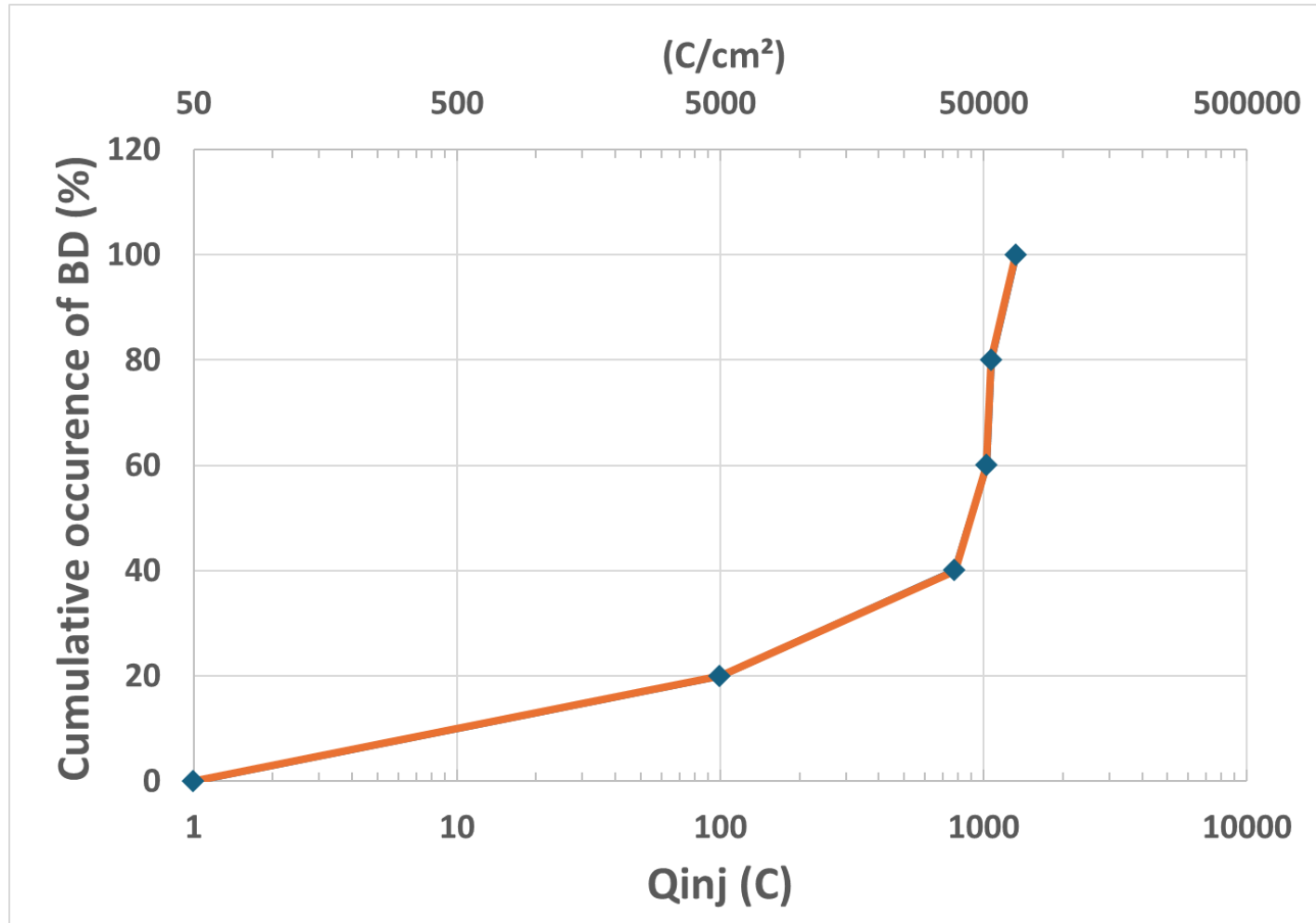
Impact of Current Density

Probability of occurrence of Bipolar Degradation (BD)



- BD observed above
1000 A/cm^2 ~ 1500 A/cm^2

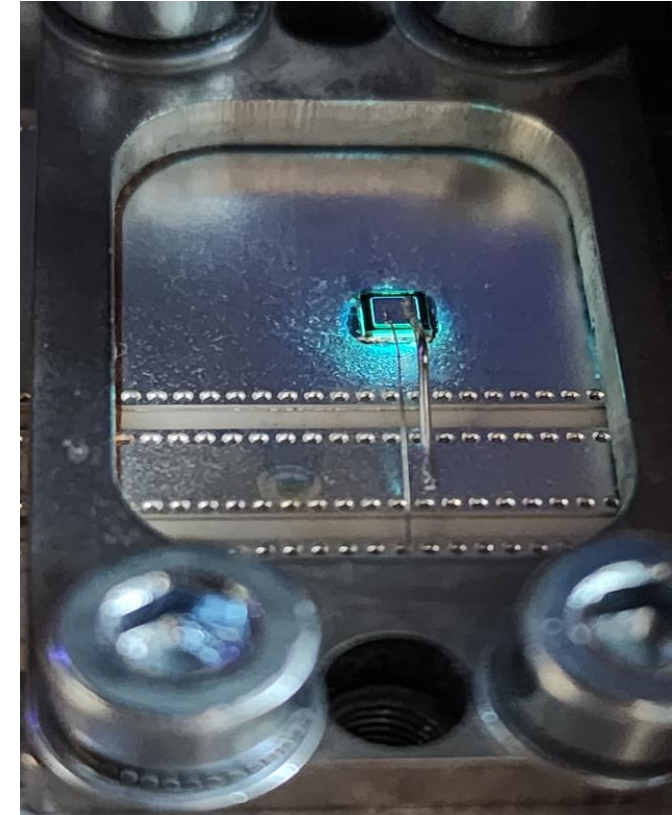
Impact of Injected Charge



- When Bipolar Degradation occurs, it triggers around 50 kC/cm²

Summary

- First study of Bipolar Degradation as a function of accumulated injected charge
- Introduction of In-situ KP measurements (ability to differentiate BD from BW degradation)
- Study of impact of Temperature, Stress current density and Injected charge without parameter interaction.



Conclusions

Temperature is not a first order parameter

Bipolar Degradation triggers above $1000\text{A}/\text{cm}^2$

Critical injected charge was found to be around $50\text{kC}/\text{cm}^2$

Outlook

**Improvement on effective
Pulse Width**

**Statistical observation for
all parameters**

UV Photoluminescence

**Test Bench improvement
(PCB integration to test
more DUTs at a time)**



Image References

[1] Tsuchida, Hidekazu, et al. "Suppression of Bipolar Degradation in 4H-SiC Power Devices by Carrier Lifetime Control." *2019 IEEE International Electron Devices Meeting (IEDM)*. IEEE, 2019.

[2] Hatta, Naoki, et al. "Reduction of Forward Bias Degradation in 4H-SiC PiN Diodes Fabricated on 4H-SiC Bonded Substrates." *Key Engineering Materials* 948 (2023): 107-113.

References

- [1] Bergman, J. Peder, et al. "Crystal defects as source of anomalous forward voltage increase of 4H-SiC diodes." *Materials Science Forum*. Vol. 353. 2001.

- [2] Tsuchida, Hidekazu, et al. "Suppression of Bipolar Degradation in 4H-SiC Power Devices by Carrier Lifetime Control." *2019 IEEE International Electron Devices Meeting (IEDM)*. IEEE, 2019.

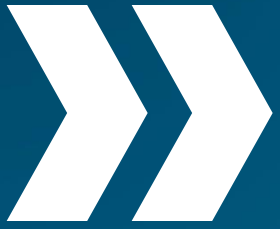
- [3] Hatta, Naoki, et al. "Reduction of Forward Bias Degradation in 4H-SiC PiN Diodes Fabricated on 4H-SiC Bonded Substrates." *Key Engineering Materials* 948 (2023): 107-113.

- [4] Omote, Kazuhiko. "Crystal defects in SiC wafers and a new X-ray topography system." *The Rigaku Journal* 29.1 (2013).

- [5] Harada, Shunta, et al. "Suppression of stacking fault expansion in a 4H-SiC epitaxial layer by proton irradiation." *Scientific Reports* 12.1 (2022): 13542.

- [6] Laha, S., et al. "Milliseconds Power Cycling (PCmsec) driving bipolar degradation in Silicon Carbide Power Devices." *CIPS 2024; 13th International Conference on Integrated Power Electronics Systems*. VDE, 2024.

- [7] Brosselard, Pierre, et al. "The effect of the temperature on the Bipolar Degradation of 3.3 kV 4H-SiC PiN diodes." *2008 20th International Symposium on Power Semiconductor Devices and IC's*. IEEE, 2008.



Thank You for your attention!

Want to know more?

Meet us at booth 68!



Download

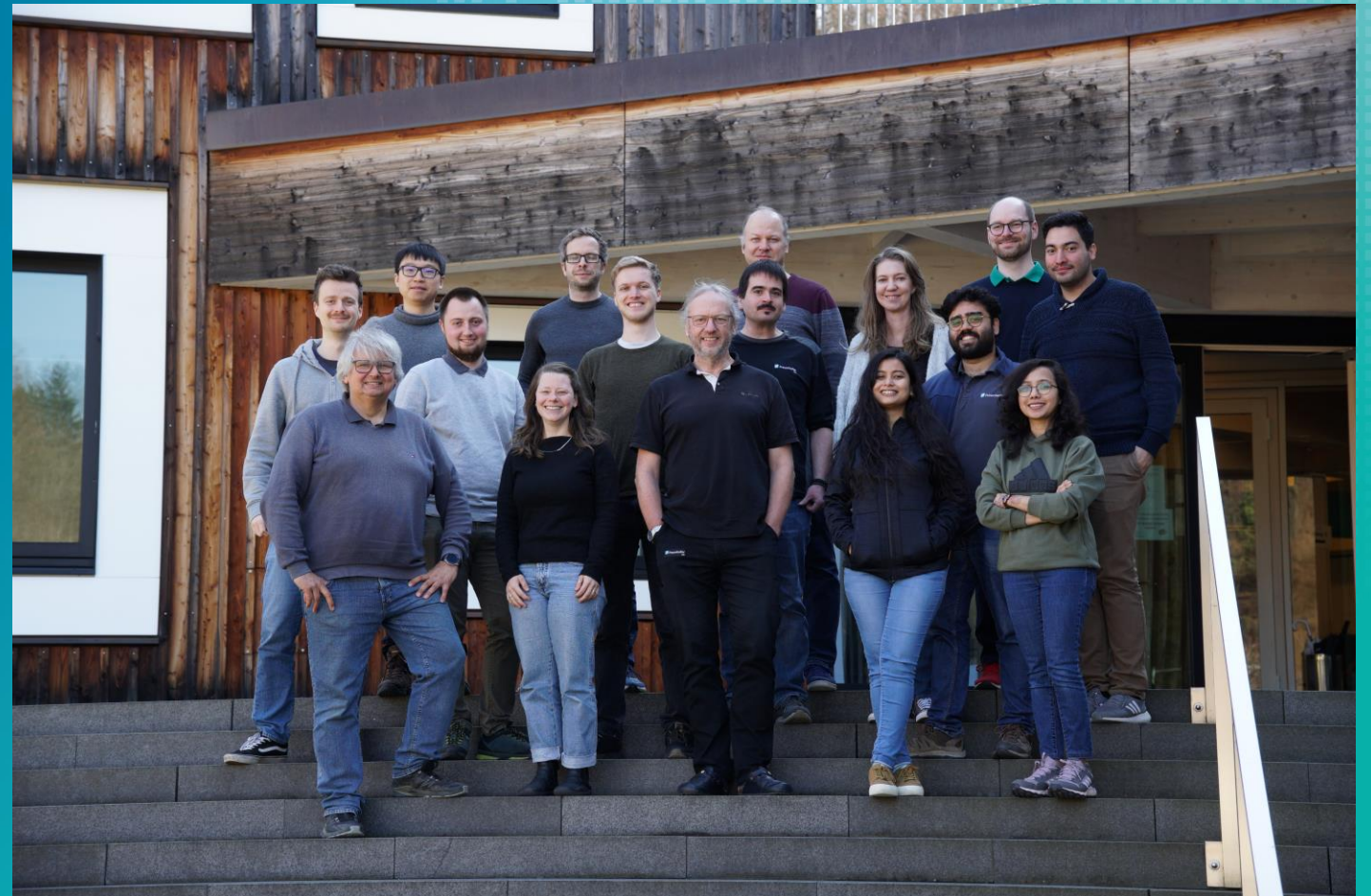
Contact

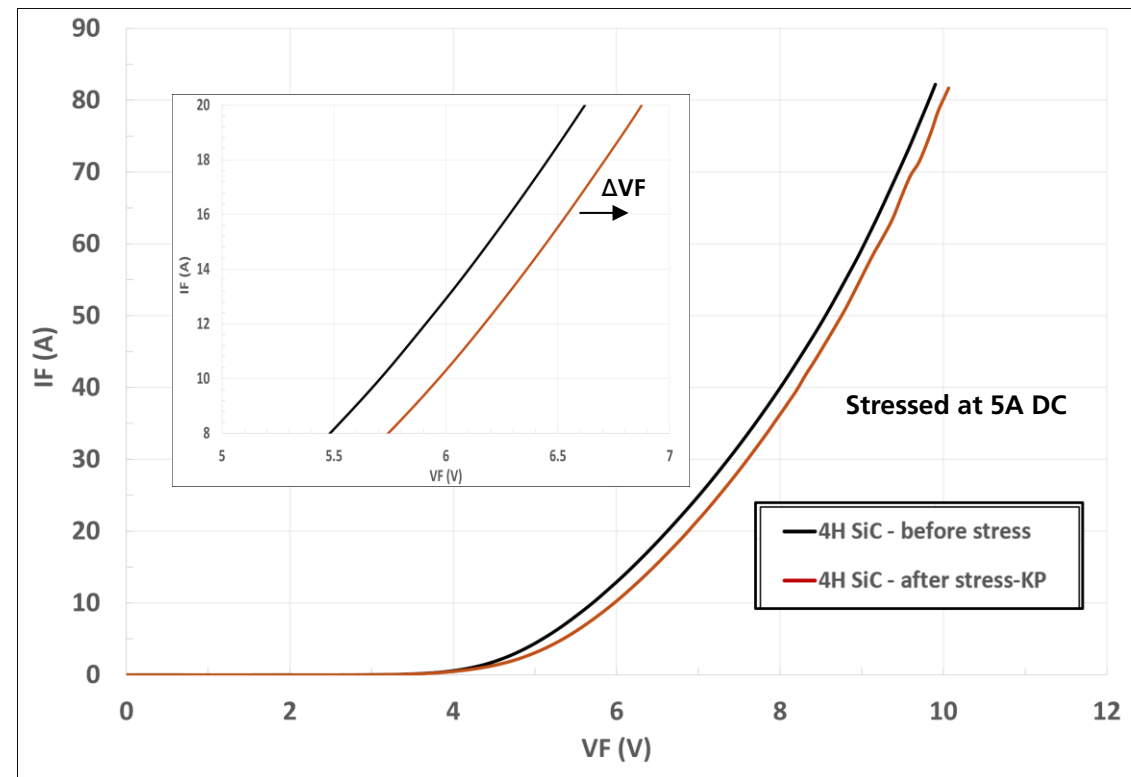
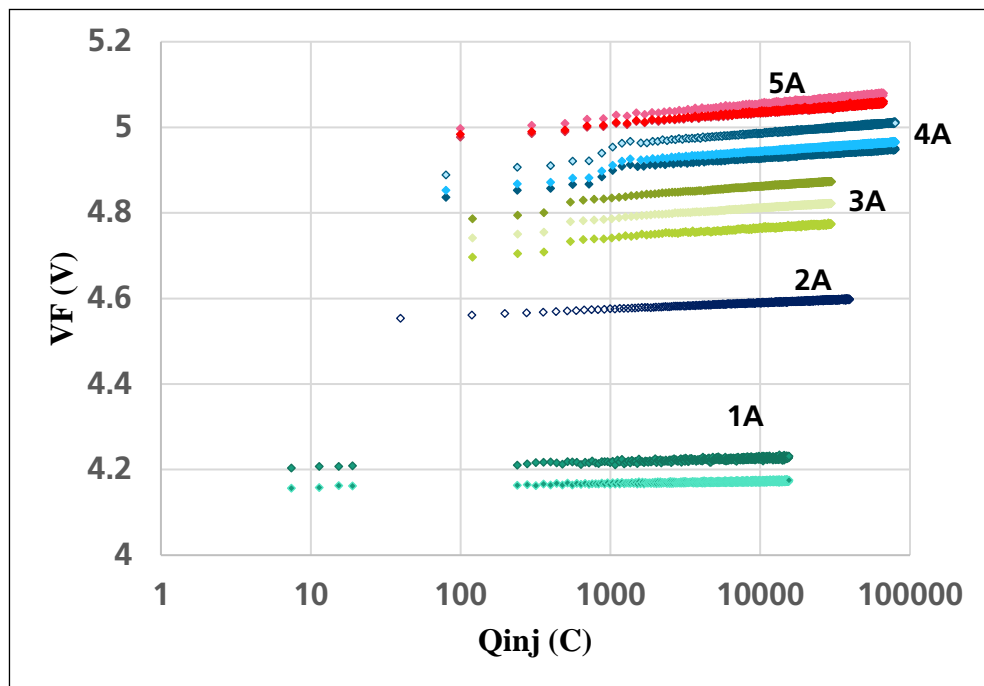
Vehicle Eletronics – Test & Reliability
Rijuta Bagchi, Scientific Research Associate
Tel. +49 9131 761-446
rijuta.bagchi@iisb.fraunhofer.de

Fraunhofer IISB
Schottkystraße 10
91058 Erlangen
www.iisb.fraunhofer.de



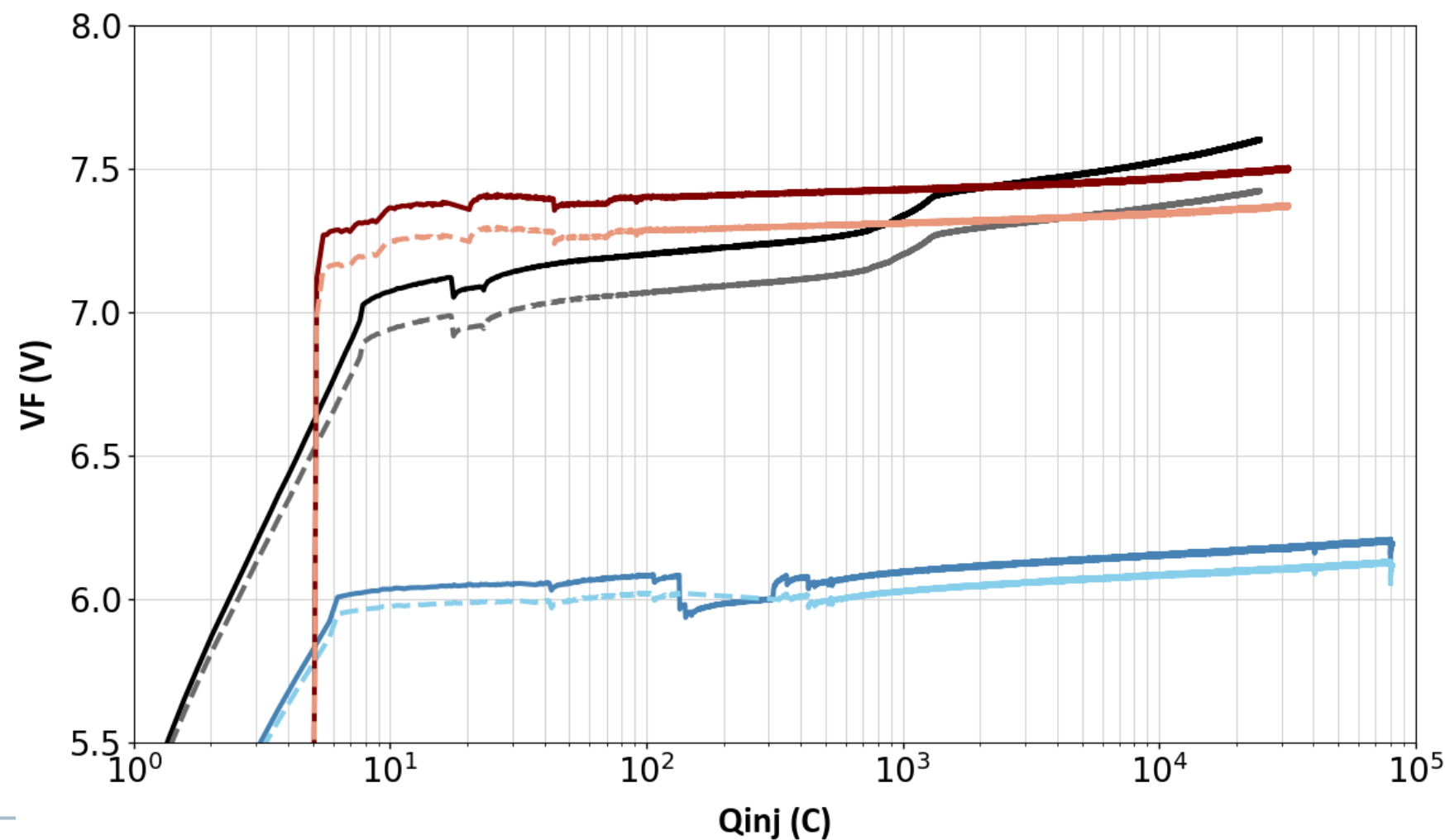
Fraunhofer Institute for Integrated
Systems and Device Technology IISB





Results: Observed V_F shift in the post characterization results.

Backup

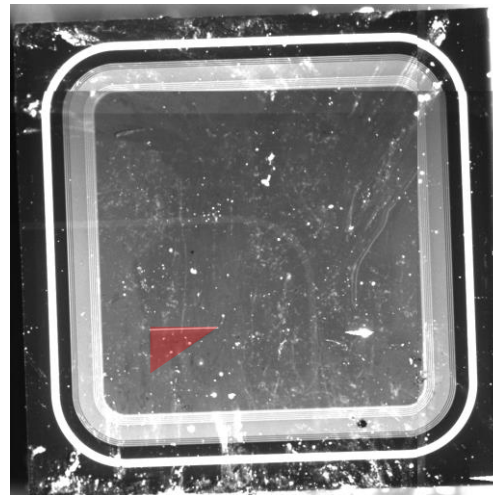


Photoluminescence Results

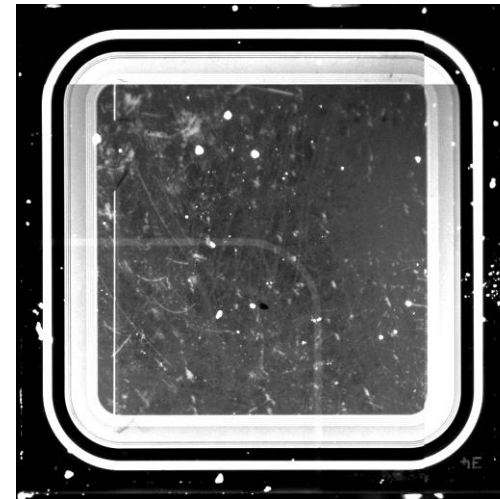
Stressed at 35A (1750 A/cm^2)



Stressed at 45 A (2250 A/cm^2)



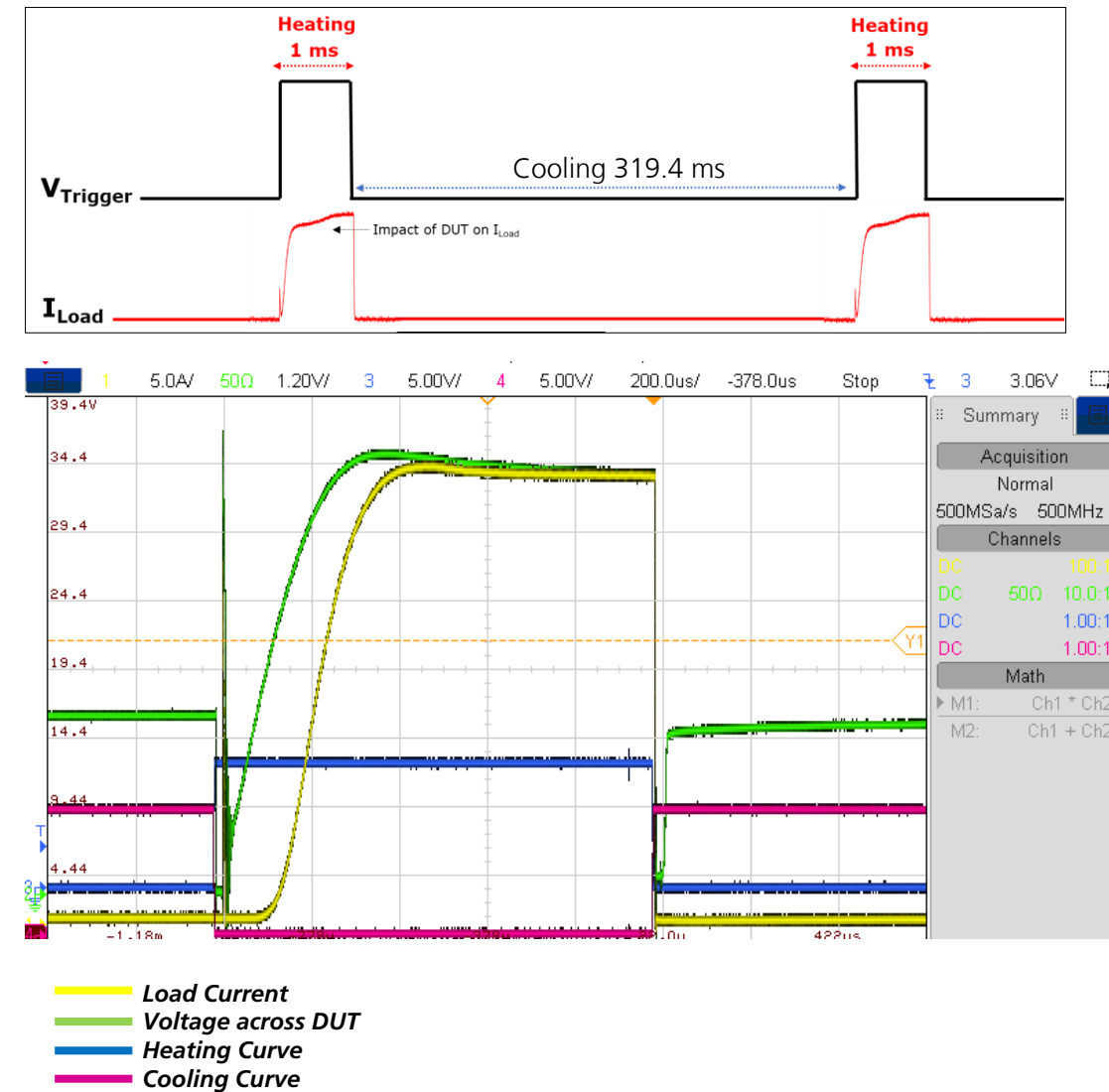
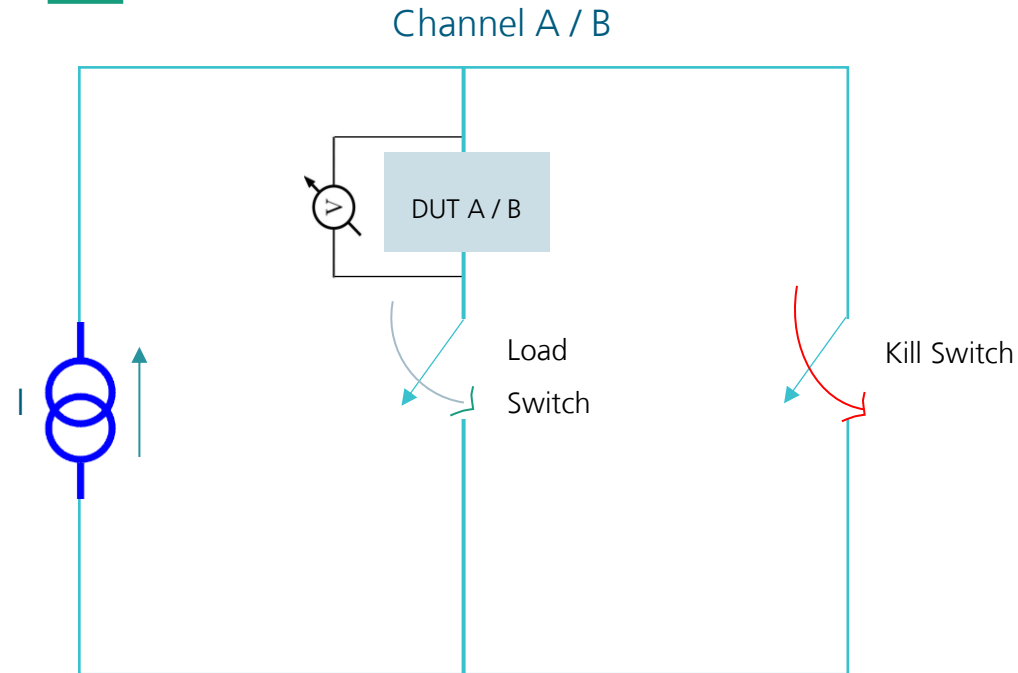
Stressed at 30A (1500 A/cm^2)



W08_C19

Sweep test for very short pulsed PCmsec test

Sweep test for very short pulsed PCmsec test

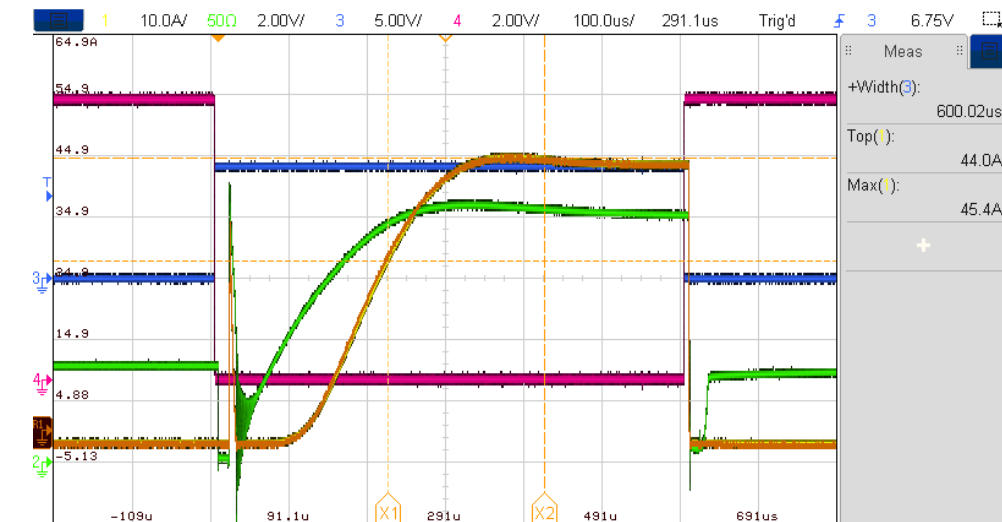


- *Parameters : Load Current = 45 A (Coolant Temperature = 25 °C -28°C (Glycol + water))*
- *PC_{msec} parameters : t_{on} = 600μs and t_{cooling/off} = 319.40 ms*

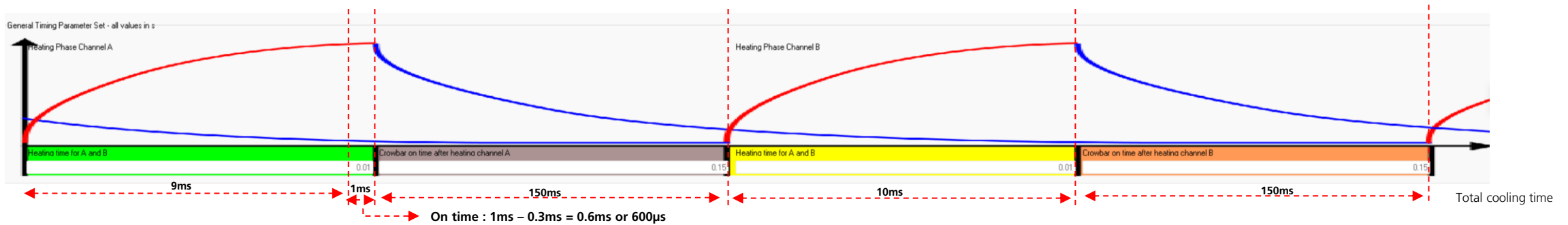
Pcmsec

45A, ~600k cycles

Current Pulse for W08



— Load Current
— Voltage across DUT
— Heating Curve
— Cooling Curve



- Parameters : Load Current = 45 A (Coolant Temperature = 25 °C -28°C) (Glycol + water)
- PC_{msec} parameters : $t_{on} = 600 \mu s$ and $t_{cooling/off} = 319.4 ms$ (150ms+150ms+10ms+0.4ms)